

## REFERENCES

- Benitez, J. (1993). Process Engineering and Design for Air Pollution Control. New Jersey: PTR Prentice Hall.
- Bonacci, J. A., Farruato, R. J., and Heck, R. M. (1989). Encyclopedia of Environmental Control Technology. Texas: Gulf Publishing.
- Borgharkar, N. S., and Abraham, M. A. (1994). Monomethylamine oxidation over palladium catalysts. Chemical Engineering Science, 49(24A), 4501-4513.
- Fogler, H. S. (2<sup>nd</sup> Eds.). (1992). Elements of chemical Reaction Engineering. New Jersey: PTR Prentice Hall.
- Heck, R. M., Farruato, R. J., and Heck, R. M. (1989). Catalytic Air Pollution Control. New York: Van Nostrand Reinhold.
- Kuwabara, N. H., Okuhara, T., and Missono, M. (1992). Catalytic removal of trimethylamine by selective oxidative decomposition to N<sub>2</sub>, CO<sub>2</sub>, and H<sub>2</sub>O over copper-exchanged zeolites. Chemistry Letters (The Chemical Society of Japan), 947-950.
- Lee, J. H., and Trimm, D. L. (1995). Catalytic combustion of methane. Fuel Processing Technology, 42, 339-359.
- Lester, G. R., and Homeyer, S. T. (1993). Catalytic destruction of organic volatile nitrogen compounds. Environmental Catalysis Symposium (National Meeting of the American Chemical Society). Colorado: AlliedSignal Research and Technology.
- McKetta, J. J., and Cunningham, W. A. (1997). Encyclopedia of Chemical Processing and Design. New York and Bansel: Marcel Dekker.
- Noordally, E., Richmond, J. R., and Tahir, S. F. (1993). Destruction of volatile organic compounds by catalytic oxidation. Catalysis Today, 17, 359-366.

- Noyes, R. (1991). Handbook of Pollution Control Processes. New Jersey: Noyes Publications.
- Othmer, K., and Kroschwitz, J. I. (Eds.). (1992). Encyclopedia of Chemical Technology. New York: John Wiley & Sons.
- Papaethimiou, P., Ioanides, T., and Verykios, X. E. (1997). Combustion of non-halogenated volatile organic compounds over group VIII metal catalysts. Applied Catalysis B: Environmental, 13, 175-184.
- Rossin, J. A., and Campell, J. A., (1998). Catalytic oxidation of organic nitrogen containing compounds. US Patent 5,720,931.
- Satterfield, C. N. (1991). Heterogeneous Catalysis in Industrial Practice. New York: McGraw-Hill, Inc.
- Spivey, J. J. (1997). Review: Complete catalytic oxidation of volatile organics. Industrial Engineering Chemistry Research, 26(11), 2165-2180.
- Van der Vaart, D. R., Vatvuk, W. M., and Wehe, A. H. (1991). Thermal and catalytic incinerators for the control of VOCs. Journal of Air Waste Management Association, 41(1), 92-98.
- Wang, Y., Shaw, H., and Farrauto, R. J. (1991). Catalytic control of air pollution of trichloroethylene over 1.5% platinum supported on alumina. American Chemical Society Symposium Series. New York.
- Wasfi, A. K., Mathur, G. P., Pierre, C. C., and Gnyp, A. W. (1978). Evaluation of catalysts for vapor phase oxidation of odorous organic compounds. Atmospheric Environment, 12, 2389-2398.
- Windawi, H., and Zhang, Z. C. (1996). Catalytic destruction of halogenated air toxins and the effect of admixture with VOCs. Catalysis Today, 30, 99-105.

Yu, T. C., Shaw, H., and Farrauto, R. J. (1991). Catalytic oxidation of trichloroethylene over PdO catalyst supported on alumina. American Chemical Society Symposium Series. New York.

## APPENDICES

### Appendix A. Physical property of diethylamine (DEA)

Physical properties of diethylamine such as formula weight, specific gravity, and boiling point are illustrated in this appendix. Additional data of vapor pressure up to 1 atm are also included. *Robert, H. P.* (*6<sup>th</sup> Eds.*). (1984). *Perry's Chemical Engineers' Handbook*. Malaysia: McGraw-Hill, Inc.

#### Physical Properties:

Name	: Diethylamine
Formula	: $(C_2H_5)_2NH$
Formula weight	: 73.14
Specific gravity	: 0.712 at 15°C referred to water at 15 °C
Boiling point (°C)	: 55.5

#### Vapor Pressure of Diethylamine, up to 1 atm:

Temperature (°C)	Vapor Pressure (mmHg)
-33.0	10
-22.6	20
-11.3	40
-4.0	60
6.0	100
21.0	200
38.0	400
55.5	760

**Appendix B.** Kinetic data for determining reaction order with respect to diethylamine concentration at 250 °C.

Run No.	Concentration of DEA (ppm)	Concentration of $O_2$ (vol %)	Reaction rate, $r (10^{-7})^*$
1	1,000	21	11.54
2	2,000	21	15.10
3	3,000	21	19.70
4	4,000	21	23.84
5	5,000	21	27.60
6	6,000	21	29.72
7	7,000	21	33.05
8	8,000	21	36.53
9	9,000	21	38.20
10	10,000	21	39.35

**Appendix C.** Kinetic data for determining reaction order with respect to diethylamine concentration at 265 °C.

Run No.	Concentration of DEA (ppm)	Concentration of O <sub>2</sub> (vol %)	Reaction rate, $r (10^{-7}) *$
1	1,000	21	18.26
2	2,000	21	23.88
3	3,000	21	30.40
4	4,000	21	35.58
5	5,000	21	41.14
6	6,000	21	45.23
7	7,000	21	49.09
8	8,000	21	52.79
9	9,000	21	55.86
10	10,000	21	59.15

**Appendix D.** Kinetic data for determining reaction order with respect to oxygen concentration at 250 °C.

Run No.	Concentration of DEA (ppm)	Concentration of $O_2$ (vol %)	Reaction rate, $r (10^{-7})^*$
1	2,000	10	11.39
2	2,000	15	11.98
3	2,000	20	11.54
4	2,000	25	11.66
5	2,000	30	11.48
6	2,000	35	11.94

**Appendix E.** Kinetic data for determining reaction order with respect to oxygen ( $O_2$ ) concentration at 265 °C.

Run No.	Concentration of DEA (ppm)	Concentration of $O_2$ (vol %)	Reaction rate, $r (10^{-7})^*$
1	2,000	10	18.35
2	2,000	15	18.52
3	2,000	20	18.21
4	2,000	25	18.61
5	2,000	30	18.41
6	2,000	35	18.50

**Appendix F.** Kinetic data for determining apparent activation energies.

Run No.	Reaction temperature (°C)	Reaction rate $r (10^{-7})^*$	Kinetic region
1	250	11.81	Chemical kinetic
2	265	19.99	
3	275	26.75	
4	280	61.80	Pore diffusion
5	290	73.12	
6	295	78.00	Mass transfer
7	300	239.21	
8	330	264.30	
9	350	278.20	

\* units of the reaction rate, gmoles  $CO_2 \cdot g^{-1} catalyst \cdot sec^{-1}$



## CURRICULUM VITAE

**Name :** Rungrodj Roonprapun

**Birth Date :** May 25<sup>th</sup>, 1972

**Nationality :** Thai

### **University Education:**

1991-1995 Bachelor's Degree of Engineering

Chemical Engineering and Process, Faculty of Engineering,  
King Mongkut's Institute of Technology North Bangkok,  
Thailand.

### **Working Experience:**

1995-1996 Quality Engineer

Toshiba Display Devices (Thailand) Co., Ltd.

1996-1997 Process Engineer

Philips Semiconductors (Thailand) Co., Ltd.